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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **Manabu NAKAMURA et al.**

Group Art Unit: **2891**

Application Number: **10/659,748**

Examiner: **Bradley Smith**

Filed: **September 11, 2003**

Confirmation Number: **3468**

For: **METHOD OF MANUFACTURING SEMICONDUCTOR DEVICE
HAVING GATE OR TUNNEL INSULATION FILM (As herein
amended)**

Attorney Docket Number: **031140**

Customer Number: **38834**

AMENDMENT UNDER 37 C.F.R. § 1.111

Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

June 22, 2005

Sir:

In response to the Office Action dated March 22, 2005, Applicants amend the claims as follows and submit the following remarks.

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims begin on page 3 of this paper.

Remarks/Arguments begin on page 8 of this paper.